

Analog and RF Requirements for Advanced CMOS Nodes: The SOI Perspective

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Outline



- Wireless Business Overview: where are we heading to ?
- Tablets and Smartphones Build Of Manufacturing
- Is SOI CMOS Technology a good alternative for today challenges ?
 - Application Processor Performances Booster
 - Digital Baseband Performances/Consumption Tradeoff Improvement
 - RF transceiver performances improvement
 - Connectivity Combo Chip integration improvement
 - Front End Module Integration on Silicon
- 4G System Architectures Trend: new challenges to come
- Can SOI CMOS Technology address future RF challenges ?
- Conclusion and Perspectives



Mobile phone market is quickly moving to smartphones, in 2Q12 smartphones represent 38% of the market (~153.9 millions units) in comparison with 25% in 2Q11 representing an increase of 42% year-over-year.





Source: IHS iSuppli Research, August 2012

- Apple continues its inroad in the mobile market (~26 millions iPhone units in 2Q12, up by 27% in comparison with 2Q11) targeting the premium customers (capturing 73% of 1Q12 handset profits with a market share of only 9% of the global handset market).
- Apple and Samsung now dominate the smartphone market with combined market share of nearly 50%.



 Google is the one who delivered a competitive solution to Apple with the Android OS and its OEM community (HTC, Huawei, LG, Motorola, Samsung, Sony Ericsson, ZTE).

Mobile Operating System	1Q12 Unit Shipments	1Q12 Market Share	1Q11 Unit Shipments	1Q11 Market Share	Year-over- Year Change
Android	89.9	59.0%	36.7	36.1%	145.0%
iOS	35.1	23.0%	18.6	18.3%	88.7%
Symbian	10.4	6.8%	26.4	26.0%	-60.6%
BlackBerry OS	9.7	6.4%	13.8	13.6%	-29.7%
Linux	3.5	2.3%	3.2	3.1%	9.4%
Windows Phone 7/Windows Mobile	3.3	2.2%	2.6	2.6%	26.9%
Other	0.4	0.3%	0.3	0.3%	33.3%
Total	152.3	100.0%	101.6	100.0%	49.9%

Top Six Smartphone Operating Systems, Shipments, and Market Share, 2012 Q1 (Units in Millions)

Source: IDC Worldwide Mobile Phone Tracker, May 24, 2012

- Android became the leading smartphone platform in 4Q10 and in 2Q12 Android based smartphones represent 59% of the smartphone market (up 145% year-over-year).
- Emerging markets (China, India, and Brazil) represent now the strongest market opportunities for smartphone makers. So chipset cost matters, we can already see a fierce competition on the Chinese market (with MediaTek to ship 95 millions of its low cost MT6575/6577 solutions in 2012 and expected to reach 200 millions parts in 2013).



 Coming back to hardware, *LTE* capability is currently the *next hot feature* everybody is looking at. The *US* market is *leading* the *LTE deployment* with carriers in Japan and South Korea investing heavily in 4G LTE technology deployments.



Apple iPhone 5



- 4G devices are redefining smartphone formats, moving to larger touch screens (4.5" or 5") while pushing the thickness of the device to new record low (< 8 mm).
- Moreover, as we will discuss later, moving to 4G will bring us to deal with a lot of new challenges since we will have to support numerous new frequency bands.



But smartphone is not the only force in action here, tablet is also playing a key role with 24.994 Millions tablet shipped in 2Q12 (up 66.2% year-over-year).



- Apple and the *iPad* (17.042 millions units in 2Q12, up 84.2% over 2Q11) are currently holding 61.5% market share in 2Q12 (in comparison with 75% in 2011) while Android tablet now holds 38.5% of the market mainly thanks to Samsung and Amazon.
- It is interesting to note that the *rise of the tablet market* is coming *at the expense of the netbook* one and in the *future* it is believed that *tablet could* even *supplant laptop*.

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- So, *wireless business* is *fueling* the *semiconductor industry* with the rapid expansion of *smartphones* and *tablets*.
- According to researches, original equipment manufacturers (*OEMs*) have spent more on semiconductors for wireless devices than computers in 2011 (\$55.4 billions on semiconductors for phones and tablets in 2011, as compared to \$53.1 billions on PC silicon)



 So the key question is now if SOI CMOS technology can play a role here in order to bring product differentiation or address challenges faced by the wireless industry.

Smartphones BOM



Apple iPhone 4 Teardown:



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Tablets BOM



Apple iPad 2 3G Teardown:



Tablets and Smartphones BOM



In the end, *smartphones* and *tablets* wireless IC *BOM* are *almost the same*... Then, we can summarize tablets and smartphones wireless IC requirement as follow:



The key question is now to know if SOI CMOS technology can help in order to address the current challenge faced by those 5 kinds of ICs ?

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Is CMOS SOI a Good Alternative ?



- We can summarize the requirements of wireless business for advanced CMOS technology as follow:
 - <u>High performances application processor:</u>
 Ensure *high speed* operation under *low power consumption* constraints
 - <u>High speed baseband processor:</u> Help to *improve* the *cost/performance/power consumption tradeoff*
 - <u>3G/LTE *RF Transceiver:*</u>

Help to *reduce* the *power consumption* and *improve* the *RF performances*

Combo <u>connectivity chip:</u>

Enable the *integration* of remaining off chip features

Front End Modules:

Enable the *integration* of FEM *on silicon* in order to improve both integration and cost

The good question now is to know if SOI can help to address any of those requirements in a more time and cost effective manner than traditional bulk CMOS technologies ?

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Application Processor Challenges



 Clearly, *application processor* business is *driven by performances* in order to make ARM CPU the dominant processor platform leveraging mobile application trend.



In order from left to right:

A4	A5	A5 Gen 2	A5X	A6		
45 nm	45 nm	32 nm	45 nm	32 nm		
7.3 mm x 7.3 mm	10.09 mm x 12.15 mm	8.19 mm x 8.68 mm	12.9 mm x 12.8 mm	9.70 mm x 9.97 mm		
http://www.presence-pc.com/actualite/iPhone5-A6-performances-48851/#xtor=RSS-11						

- Main players are currently delivering 1.5 GHz dual core Cortex A9 ARM processor, aggressively moving to quad core Cortex A9 and to dual Cortex A15.
- In this quest, access to most advanced CMOS node (28 nm and below) has been so far the way to go.

Baseband Processor Challenges



Moving from HSPA+ (12 Mbps) to 4G/LTE (100 Mbps), the design of advanced baseband processor becomes more and more challenging.



Figure 4: Cellular Radio Computation Levels (MOPS) versus Download Data Rates (Mbits/sec)



 Baseband processor manufacturers have now to deliver cost effective and power efficient DSP capable of delivering 100 000s MOPS (millions of operation per second).

Baseband Processor Challenges



Up to now the use of most advanced CMOS node has been the answer.



GSM Digital Baseband Evolution

'Wireless Industry Trends and Technology', Bill Krenik, Senior Director, Advanced Technology, Texas Instruments, BWRC 2007 Winter retreat, 8 January 2007

Can SOI technology help to achieve better cost/performance/consumption tradeoff ?

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SOI CMOS for Application and Baseband Processor

- In order to address both applications processor and baseband processor challenges, ST is committed to Fully Depleted-SOI technology.
- ST believes that FD-SOI can deliver the best speed/power performances ever.

Speed / Leakage Power Trade-offs

Speed / Leakage Power Trade-offs



"28 and 20 nm FDSOI Technology Platforms'", Giorgio Cesana, SOI Consortium (www.soiconsortium.org), February 2012.

3G RF Transceiver Challenges



RF cellular *transceiver* has also achieved a very *high level of integration* (with 65 nm SOC available on the market).





M. Nilsson et al., "A 9-band WCDMA/EDGE transceiver supporting HSPA evolution", IEEE International Solid-State Circuits Conference (ISSCC), 2011, Page(s): 366 - 368



A. Hadjichristos et al., "Single-chip RF CMOS UMTS/EGSM transceiver with integrated receive diversity and GPS", IEEE International Solid-State Circuits Conference (ISSCC), 2009, Page(s): 118 - 119

 But since *RF and analog parts* consume the *main part of die*, moving to technology beyond 65 nm does not bring necessary any economical advantage.

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3G RF Transceiver Challenges



With the support of new bands and the integration of new features such as antenna diversity, the design of advanced RF transceiver becomes even more challenging and the die size has to increase.



- GSM bands: GSM850, EGSM900, DCS1800, PCS1900
- WCDMA bands: I, II, III, IV, V, VI, VIII, IX, X and XI
- LTE bands 1, 4, 7, 13, 17
- <u>14 differential RF inputs for the receiver</u>
 - 9 differential RF inputs on the primary receiver
 - <u>5</u> differential RF inputs on the diversity receiver
- <u>8 RF outputs</u> on transmitter
- <u>DigRF</u>3G and 4G interfaces to the baseband IC
- Auxiliary <u>SPI to control PAs</u>, switching regulators and antenna switch

http://www.fujitsu.com/us/services/edevices/microelectronics/rftransceiver/I10/

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3G RF Transceiver Challenges



 Moreover, since higher data rate are requested (100 Mbps) the wireless industry will have to support carrier aggregation for LTE.



Eiko Seidel, Junaid Afzal, Günther Liebl, Nomor Research GmbH, "White Paper – Dual Cell HSDPA and its Future Evolution", January 2009.

This means that the *power consumption* of LTE *RF transceiver* will be the *key feature to be optimized* in the coming years.



- Integration of high quality passive components in standard bulk silicon technology is not obvious (due to the use of lossy silicon substrate) and limits RF transceiver performances (consumption, sensitivity, output power,...).
- Thanks to the dielectric isolation offered by buried oxide, we can use High Resistivity (HR) substrate in SOI Technology.



CPW transmission line performances on SOI

180 GHz CPW filter achieved on SOI

 Then, measured losses on HR SOI are comparable with InP, which is a key advantage in order to improve RF transceiver performances.



- High quality factor inductors are mandatory for most of RF applications. However, it becomes harder and harder to offer such components in advanced standard CMOS technology due to BEOL evolution.
 - HR SOI CMOS enables to achieve Q~20@5GHz in 65 nm BEOL, which is not feasible in bulk without Thick Copper option



"On the Design of High Performance RF Integrated Inductors on High Resistively Thin Film 65 nm SOI CMOS Technology", F. Gianesello et al., IEEE Topical Meeting on Silicon Monolithic Integrated Circuits in RF Systems 2008, SiRF 2008, pp. 98 - 101, 23-25 Jan. 2008

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 SOI optimized integrated planar inductors have been used for the design of a 5 GHz Low Noise Amplifier



S_{21} = 14 dB, NF = 1.4 dB, S_{11} et S_{22} < -10 dB Id = 8mA and Vdd = 1.2 V

"5 GHz 1.4 dB NF CMOS LNA integrated in 130 nm High Resistivity SOI technology ", F. Gianesello, Daniel Gloria, Christine Raynaud, Samuel Boret, International Symposium on Integrated Circuits (ISIC-2007), 26 - 28 September 2007, Singapore

 State of the art performances have been measured, demonstrating the added value of SOI CMOS due to its compatibility with HR substrate.

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Equivalent results have been obtained on a 5 GHz VCO, improved inductor quality factor achieved on SOI CMOS inductor helps to improve achievable noise figure (or reduce the power consumption)



"A low-power 5 GHz CMOS LC-VCO optimized for high-resistivity SOI substrates", P. Delatte et al., page(s): 395- 398, IEEE ESSCIRC 2005,

 This could be a key advantage for 3G RF transceivers design, especially concerning wideband and high performance VCO design (which is a key challenge).

Combo Connectivity Chip Challenges

 Connectivity features (WiFi, Bluetooth, FM Radio and GPS) are now a commodity and then a high level of integration has been achieved in order to deliver cost effective combo chip solution through a SOC approach.



33% die size reduction



Broadcom *BCM* 4329 die (65 nm)

Broadcom BCM 4330 die (40 nm)

But beyond 40 nm, the economical gain is not obvious to demonstrate:

"28nm is the first process shrink which doesn't deliver a cheaper chip ... unless you need the advanced process because of performance reasons or die-size reasons, you're not going to get a cost benefit from converting to the new node"

Scott McGregor, CEO of Broadcom

Combo Connectivity Chip Challenges

 Moreover, since connectivity is now a commodity, main players are trying to differentiate themselves by integrating the last off chip features (2.5 GHz PA, ...).





The two remaining key blocks, not yet integrated in CMOS, are the 5 GHz PA and the SP3T antenna switches. Then, if SOI CMOS technology demonstrates any advantage concerning the integration of FEM on silicon, the advantage for connectivity chip would then be obvious.

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Front End Module Challenges





Most of the cost of the cellular RF ICs are in the FEMs (~70% of the RF BOM), the level of integration of FEM has to be improved in order to achieve both lower cost and reduced PCB area (which is a key concern in densely packaged smartphones).

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Front End Module Challenges





2.5G RF TX (transmit) module for cellular (GSM) applications (6mm x 5mm) – C. Raynaud et al., SOI Conference Short Course 2007

M. Nilsson et al., "A 9-band WCDMA/EDGE transceiver supporting HSPA evolution", IEEE International Solid-State Circuits Conference (ISSCC), 2011, Pages: 366 - 368

FEM are still using a module making an assembly of a variety of technologies (III-V HBT, IPDs, LTCC and CMOS). FEM is now the only space in a RF system where integration can be greatly improved, can SOI CMOS play help to integrate FEM on silicon?

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- Since most of the complexity and cost are in the FEMs, a lot of researches have been
 performed during past years in order to *improve the integration level of FEM* and to *use
 CMOS technology as much as possible to lower cost*.
- In this quest, the *integration of the antenna switches on SOI* has played a key role, mainly because this key block is known as *not feasible in Bulk CMOS*. *SOI antenna switches* have now demonstrated their ability to deliver the appropriate performances with a cost effective approach.



"Cellular antenna switches for multimode applications based on a Silicon-on-Insulator technology", A. Tombak et al., Radio Frequency Integrated Circuits Symposium (RFIC), 2010 IEEE, Page(s): 271 - 274



 Main FEM manufacturers (RFMD, Skyworks, ...) are currently delivering millions of CMOS SOI antenna switches to the market.



SP6T Switch Cost of Ownership



Antenna switches in handsets - Technology breakdown

"SOI Substrate for RF Applications", E. Desbonnets, EuroSOI 2010 Tutorial, Grenoble, 25-27 January 2010.

Cost has been the first motivation to move antenna switches business on SOI

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 Moreover, as we can see below, *FEM design is all about passive* (which have been up to now integrated using LTCC or IPD technologies).



Dual Band GSM/GPRS FEM

- Since SOI is fully compatible with High Resistivity (HR) substrates, high performance passive components can be integrated on SOI.
- Then, we can think about *lowering the cost of FEM* by directly *integrating FEM passive functions* (harmonic filters, diplexer, balun, ...) on SOI along with antenna switches.



A GSM/DCS diplexer has been successfully designed in ST 130 nm SOI CMOS technology, achieving a very compact form factor.



"Integration of cellular front end modules on advanced high resistivity SOI RF CMOS technology", F. Gianesello et al., 2011 IEEE Topical Conference on Power Amplifiers for Wireless and Radio Applications (PAWR), pp. 29 - 32, 16-19 Jan. 2011

- Excellent agreement is obtained between simulation and measurement (confirming the accuracy of inductor scalable models available in ST design kit).
- Promising performances have been achieved, insertion losses in both bands are
 < 1 dB, which is clearly competitive with current LTCC or IPD solutions.



A DCS harmonics filter has been successfully designed in ST 130 nm SOI CMOS technology, achieving a very compact form factor.



"Integration of multi-standard front end modules SOCs on high resistivity SOI RF CMOS technology", F. Gianesello et Al., Radio Frequency Integrated Circuits Symposium (RFIC), 2010 IEEE, Pages: 229 - 232

- Excellent agreement is obtained between simulation and measurement (confirming the accuracy of inductor scalable models available in ST design kit).
- Promising performances have been achieved, insertion losses < 1 dB @ 1980 MHz, which is clearly competitive with current LTCC or IPD solutions.



- The integration of PA on SOI is the next step (and has already been demonstrated).
- Moreover CMOS technology has already demonstrated some capabilities on this topic:



Then, the integration of the whole FEM on CMOS SOI is just natural since it is the only demonstrated practical path to deliver low cost 4G FEM SOC in CMOS.

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4G Architecture Trends



 SOI CMOS technology has clearly demonstrated to be a useful technology in order to address current challenges faced by the wireless industry. But what about the future:



 RF transceiver is already largely reprogrammable, *introducing agility in the FEM is the next step* (*converged PA*, *antenna tuner* and *tunable duplexer* are the key topics).

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Antenna Tuner (1/2):

Antenna tuner features for high end smartphone is actually a hot topic



2. Hand effects typically detune antenna resonant frequency downward and cause significant mismatch at the intended operating frequency.

Tero Ranta & Rodd Novak, "Antenna Tuning Approach Aids Cellular Handsets", Microwave & RF, November 2008.



(source System Plus Consulting)

"RF Filters, PAs, Antenna Switches & Tunability for Cellular Handsets - web flyer", Yole Développement, Market , applications & Technology report – April 2012

- The goal of antenna tuner is to ensure that the antenna system will always deliver 50 Ω to the RF system whatever the environment is (for example user hand has a strong impact on antenna detuning which turns in increasing losses due to mismatch between the antenna and the SAW filter/Duplexer).
- BST technology (Agile RF, Paratek), MEMs technology (Cavendish Kinetics, wiSpry), SOS technology (Peregrine) and SOI CMOS (STMicroelectronics, IBM) are currently evaluated in order to introduce first antenna tuner solution to the market.

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Antenna Tuner (2/2):

- Leveraging SOS/SOI antenna switches experience, the development of high power (and high linearity) Digitally Tuned Capacitor (DTC) is on its way (for example Peregrine Dune[™] technology).
- The advantage of the antenna tuner has already been demonstrated practically, especially at lower frequency (700 MHz band use for LTE in the US).



 R. Whatley, T. Ranta, D. Kelly, "CMOS Based Tunable Matching Networks for Cellular Handset Applications", 2011 IEEE MTT-S International Microwave Symposium Digest (MTT), Baltimore, 5-10 June 2011.

RF MOSFETs are stacked for power handling capability (today 5 MOS for ~ 32 dBm under 50 Ω). This SOI CMOS DTC component, could play a key role in the development of tunable FEM in order to deliver low cost and highly integrated chipset solution for 4G mass market smartphones.

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Converged PA (1/2):

 Moving to 4G, it would not be practical to add new PA modules in order to support additional frequency bands. To address this problem, converged PA solution has emerged during the past years.



3G Systems Architecture:

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<u>4G Systems Architecture:</u>



Converged PA (2/2):

 Converged PA is now seen as the most realistic way to handle a high number of frequency bands in a cost effective manner (reducing the number of required PA to 2). Moreover, the solution has already proved to be practical in volume.



PowerSmart[™] Power Platform



Source: http://www.rfmd.com



10 Millions Units since April 2011



The key point in converged PA design concern the support of the tunable matching network and mode switches. SOI could enable here the full integration in CMOS in order to lower the price of the solution.

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Tunable Duplexer (1/2):

Moving to converged PA, the SAW/BAW duplexer have now to be integrated in a single module (along with the antenna switches in some cases).



High performance microwave acoustic components for mobile radios Pitschi, F.M.; Kiwitt, J.E.; Koch, R.D.; Bader, B.; Wagner, K.; Weigel, R.; Ultrasonics Symposium (IUS), 2009 IEEE International Digital Object Identifier: 10.1109/ULTSYM.2009.5441550 Publication Year: 2009, Page(s): 1 - 10

 Moving to 4G, this multimode duplexer module will reach a size which would be difficult to manage.



Tunable Duplexer (2/2):

 That is why, we can see now some *new developments to achieve tunable duplexer* (several duplexer are replaced by a tunable one over a given frequency band).



RF-MEMS for Wireless Communications, Hilbert, J.L.; Communications Magazine, IEEE Volume: 46, Issue: 8, 2008, Page(s): 68 - 74

- So basically, the goal is to develop *tunable filters using high power SOI CMOS Digitally Tunable Capacitor* (as for the antenna tuner).
- It is clearly not easy to achieve (since narrow band pass filter have to be achieved), but looks feasible and it is clearly the next integration step to be achieved.

Conclusion & Perspective



- *Wireless* technology is now clearly one of the *key drivers* of the *semiconductor industry*.
- Up to now, conventional bulk CMOS technology has been able to address the need of the wireless industry thanks to aggressive scaling roadmap.
- From the *digital point* of view, *FD-SOI technology* can offer a real *breakthrough* in order to deliver *unprecedented speed / power performances tradeoff*. FD-SOI could then play a key role in the application processor and baseband processor businesses.
- From the *RF point of view*, the *rules of the game* are *changing*:
 - *RF transceiver* have *already staled at more mature process nodes* (e.g. 65 nm)
 - Connectivity combo chip future is not clear beyond 40 nm
 - More generally, most of the *value* of the RF BOM and *challenges rely with the FEM*
- FEM integration on CMOS SOI will be the key driver in order to accommodate with this new environment since it will enable cost effective 4G FEM solutions. All FEM makers but also Chipset maker are engaged or engaging.
- This trend represents a promising opportunity for SOI in order to create added value through a « More than Moore » approach.



Thank You For Your Attention !